

CORRECTION

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Correction: Large-scalable, ultrastable thin films for electromagnetic interference shielding

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Correction for 'Large-scalable, ultrastable thin films for electromagnetic interference shielding' by Jae Seo Park et al., *J. Mater. Chem. A*, 2023, <https://doi.org/10.1039/D3TA02862C>.

The authors regret the misspelling of the email address of one of the corresponding authors, Taehoon Kim (tkim67@kims.re.kr), in the published article. The correct affiliations, including email addresses, are as shown here.

The Royal Society of Chemistry apologises for these errors and any consequent inconvenience to authors and readers.

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